## Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

## **Listing of Claims:**

1. (previously presented) A sintered silicon nitride product, comprising from about 60 to 95 mole % ß-silicon nitride, from about 1 to 8 mole % scandium oxide, from about 2.5 to 25 mole% silicon carbide, and from about 1 to 10 % scandium disilicate.

## 2-3. (cancelled)

- 4. (original) The sintered silicon nitride product of claim 1, wherein said sintered silicon nitride product comprises from about 72 to 92 mole % ß-silicon nitride, from about 3 to 18 mole % silicon carbide, from about 1 to 4 mole % scandium disilicate, and from about 3 to 6 mole % scandium oxide.
- 5. (original) The sintered silicon nitride product of claim 1, wherein said sintered silicon nitride product has a fracture toughness, as measured by the indentation strength method at a 20 kg indentation load, in the range of from about 7.7 to 8.5 MPa.m<sup>0.5</sup>.
- 6. (original) The sintered silicon nitride product of claim 1, wherein said sintered silicon nitride product has a 20-kg indentation fracture strength in the range of from about 330 to 370 MPa.

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- 7. (original) The sintered silicon nitride product of claim 1, wherein said sintered silicon nitride product has an oxidation weight gain at a temperature of 1500°C in the range of from about 0.27 to 0.38 mg.cm<sup>-2</sup>.
- 8. (original) A sintered silicon nitride product, comprising: not less than 50 mole % ß-silicon nitride, from about 0.1 to 30 mole % silicon carbide, from about 1 to 15 mole % scandium disilicate, and from about 1 to 10 mole % scandium oxide.
- 9. (original) The sintered silicon nitride product of claim 8, comprising from about 72 to 92 mole % ß-silicon nitride, from about 3 to 18 mole % silicon carbide, from about 1 to 4 mole % scandium disilicate, and from about 3 to 6 mole % scandium oxide.
- 10. (original) The sintered silicon nitride product of claim 8, wherein said sintered silicon nitride product has a sintered density of at least about 3.17 g.cm<sup>-3</sup>.
  - 11. (original) A sintered silicon nitride product, comprising:

    ß-silicon nitride grains;
    silicon carbide:
    - a grain boundary secondary phase of scandium oxide; and
- a grain boundary secondary phase of scandium disilicate, wherein said ß-silicon nitride comprises from about 72 to 92 mole %, said silicon carbide comprises from about 3 to 18 mole %, said scandium oxide comprises from about 3 to 6 mole %, and said scandium disilicate comprises from about 1 to 4 mole %.
- 12. (previously presented) A sintered silicon nitride product prepared by said starting powder mix comprising silicon nitride in the range of

from about 80 to 95 weight %, silicon carbide in the range of from about 0.25 to 10 weight %, and scandium oxide in the range of from about 5 to 12 weight %.

- 13. (original) The sintered silicon nitride product of claim 12, wherein said starting powder mix further comprises up to about 3 weight % added silicon dioxide powder.
- 14. (original) The sintered silicon nitride product of claim 13, wherein said starting powder mix has a silicon dioxide:scandium oxide molar ratio in the range of from about 0.4 to 1.
- 15. (original) A component formed from a sintered silicon nitride, said sintered silicon nitride comprising from about 60 to 95 mole % ß-silicon nitride, from about 2.5 to 25 mole % silicon carbide, from about 1 to 10 mole % scandium disilicate, and from about 1 to 8 mole % scandium oxide.
- 16. (original) The component of claim 15, wherein said component is a hot section component of a gas turbine engine.
- 17. (original) A method of preparing a sintered silicon nitride product, comprising:
  - a) providing a starting powder mix;

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- b) forming a green body from said starting powder mix; and
- c) sintering said green body to form said sintered silicon nitride product, wherein said sintered silicon nitride product comprises from about 60 to 95 mole % silicon nitride, from about 2.5 to 25 mole % silicon carbide, from about 1 to 10 mole % scandium disilicate, and from about 1 to 8 mole % scandium oxide.
- 18. (original) The method of claim 17, wherein said step a) comprises providing said starting powder mix comprising silicon nitride in the

range of from about 80 to 95 weight %, silicon carbide in the range of from about 0.25 to 10 weight %, and scandium oxide in the range of from about 5 to 12 weight %.

- 19. (original) The method of claim 17, wherein said starting powder mix further comprises added silicon dioxide powder in the range of from about 1 to 3 weight %.
- 20. (original) The method of claim 17, wherein said starting powder mix has a silicon dioxide:scandium oxide molar ratio in the range of from about 0.4 to 1.
- 21. (original) The method of claim 17, wherein said step b) comprises forming said green body by a process selected from the group consisting of isostatic dry pressing and slip casting.
- 22. (original) The method of claim 17, wherein said step c) comprises gas pressure sintering at a final pressure in the range of from about 900 to 1500 psi.
- 23. (original) The method of claim 17, wherein said step c) comprises gas pressure sintering at a temperature in the range of from about 1625 to 2025°C.
- 24. (original) The method of claim 17, wherein said step c) comprises a plurality of sintering stages.
- 25. (original) The method of claim 24, wherein said plurality of sintering stages are performed for a combined period in the range of from about 5 to 15 hours.

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- 26. (original) The method of claim 17, wherein said step c) comprises a first, a second, a third, and a fourth sintering stage.
- 27. (original) The method of claim 26, wherein said fourth sintering stage comprises sintering under nitrogen at a first sintering pressure, and during said fourth sintering stage introducing argon to provide a second sintering pressure, said second sintering pressure higher than said first sintering pressure.
- 28. (original) The method of claim 26, wherein said fourth sintering stage comprises sintering at a final pressure in the range of from about 900 to 1500 psi and a temperature of at least 2000°C.
- 29. (original) A method of preparing a sintered silicon nitride product, comprising:
- a) providing a starting powder mix, said starting powder mix comprising silicon nitride in the range of from about 80 to 95 weight %, silicon carbide in the range of from about 0.25 to 10 weight %, and scandium oxide in the range of from about 5 to 12 weight %;
  - b) forming a green body from said starting powder mix; and
- c) sintering said green body to form said sintered silicon nitride product, wherein said step c) comprises gas pressure sintering and includes a plurality of sintering stages, and wherein said sintered silicon nitride product comprises from about 60 to 95 mole % silicon nitride, from about 2.5 to 25 mole % silicon carbide, from about 1 to 10 mole % scandium disilicate, and from about 1 to 8 mole % scandium oxide, said sintered silicon nitride product having a fracture toughness in the range of from about 7.7 to 8.5 MPa.m<sup>0.5</sup>.

- 30. (original) The method of claim 29, wherein said sintered silicon nitride product has a 20-kg indentation fracture strength in the range of from about 330 to 370 MPa.
- 31. (original) The method of claim 30, wherein said starting powder mix provided in said step a) has a silicon dioxide:scandium oxide molar ratio in the range of from about 0.4 to 1.
- 32. (new) The sintered silicon nitride product of claim 12, wherein said starting powder mix has a silicon dioxide:scandium oxide molar ratio that is less than 2.0.
- 33. (new) The sintered silicon nitride product of claim 12, wherein said starting powder mix includes said silicon carbide up to 6 weight %.
- 34. (new) The sintered silicon nitride product of claim 1, wherein said starting powder mix further comprises up to about 5 weight % added silicon dioxide powder.
- 35. (new) The method of claim 17, wherein said starting powder mix has a silicon dioxide:scandium oxide molar ratio that is less than 2.0.
- 36. (new) The method of claim 17, wherein said starting powder mix includes said silicon carbide up to 6 weight %.
- 37. (new) The method of claim 17, wherein said starting powder mix further comprises added silicon dioxide powder up to 5 weight %.